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Amendments to the claims

This listing of claims will replace all prior versions and listings of the claims.

Listing of Claims:

- 1. (Currently amended) A liquid stereolithography resin comprising a first urethane acrylate oligomer, a first acrylate monomer, and a polymerization modifier; wherein the first urethane acrylate oligomer is CN964, CN963, CN966, CN990, or CN973.
- 2. (Original) The liquid stereolithography resin of claim 1, further comprising a photoinitiator.
- 3. (Original) The liquid stereolithography resin of claim 2, wherein the photoinitiator includes a phosphine oxide, an alpha-hydroxyketone, and a benzophenone derivative.
- 4. (Currently amended) The liquid stereolithography resin of claim 2, wherein the photoinitiator includes a component selected from the group consisting of a benzophenone, a benzil dimethyl ketal, a 1-hydroxy-cyclohexylphenylketone, an isopropyl thioxanthone, an ethyl 4-(dimethylamino)benzoate, SARCURE SR1135 a blend of 2,4,6-trimethylbenzoyldiphenyl phosphine oxide, 2,4,6-trimethylbenzophenone, 4-methylbenzophenone, and oligo(2-hydroxy-2-methyl-1-(4-(1-methylvinyl)phenyl)propanone, a benzoin normal butyl ether, SARCURE SR1130E a blend of oligo(2-hydroxy-2-methyl-1-(4- (1-methylvinyl)phenyl)propanone) and poly(2-hydroxy-2-methyl-1-phenyl-1-propanone), tripropyleneglycol diacrylate, an oligo(2-hydroxy-2-methyl-1-(4-(1-methylvinyl)phenyl)propanone), a 2-hydroxy-2-methyl-1-phenyl-1-propanone, a poly(2-hydroxy-2-methyl-1-phenyl-1-propanone), a trimethylolpropane triacrylate, a SARCURE SR1137 a mixture of 2,4,6-trimethylbenzophenone and 4-methylbenzophenone, a methylbenzophenone, and a

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Darocur 4265 blend of 2,4,6-trimethylbenzoyl-diphenyl-phosphineoxide and hydroxy-2methyl-1-phenyl-propan-1-one, and an Irgaeure.

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- 5. (Currently amended) The liquid stereolithography resin of claim 2, wherein the photoinitiator includes a component selected from the group consisting of a Darocur 4265 blend of 2,4,6-trimethylbenzoyl-diphenyl-phosphineoxide and hydroxy-2-methyl-1-phenyl**propan-1-one**, a phosphine oxide, a 2-hydroxy-2-methyl-1-phenyl-1-propanone, and mixtures thereof.
- 6. (Original) The liquid stereolithography resin of claim 2, wherein the photoinitiator activates polymerization of an acrylate in a wavelength range of 240 nm to 250 nm, 360 nm to 380 nm, or 390 nm to 410 nm.
- 7. (Withdrawn) The liquid stereolithography resin of claim 1, wherein the first urethane acrylate oligomer includes a polyester urethane diacrylate.
- 8. (Withdrawn) The liquid stereolithography resin of claim 7, wherein the polyester urethane diacrylate is an aliphatic polyester urethane diacrylate.
- 9. (Withdrawn) The liquid stereolithography resin of claim 1, wherein the first acrylate monomer includes a monovalent acrylate.
- 10. (Withdrawn) The liquid stereolithography resin of claim 1, wherein the first acrylate monomer includes a polyvalent acrylate.
- 11. (Withdrawn) The liquid stereolithography resin of claim 1, wherein the first urethane acrylate oligomer has formula (I):

$$A - O - \left(M^{1} - O \right)_{x}^{0} \frac{O}{H} - M^{2} - N - M^{2} - O \right)_{y}^{0} \left(M^{1} - O \right)_{z}^{z} A$$
 (I)

wherein

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each M¹ is, independently, an alkylene, an acylalkylene, an oxyalkylene, an arylene, an acylarylene, or an oxyarylene, M¹ being optionally substituted with alkyl, cycloalkyl, alkenyl, cycloalkenyl, alkynyl, acyl, alkoxy, hydroxyl, hydroxylalkyl, halo, haloalkyl, amino, silicone, aryl, or aralkyl,

each M² is, independently, an alkylene or an arylene, M² being optionally substituted with alkyl, cycloalkyl, alkenyl, cycloalkenyl, alkynyl, acyl, alkoxy, hydroxyl, hydroxylalkyl, halo, haloalkyl, amino, silicone, aryl, or aralkyl,

each A, independently, has the formula:

$$-(L-O)$$
 R^1

wherein R^1 is hydrogen or lower alkyl, each L is, independently, C_1 - C_4 alkyl, and w is an integer ranging from 0 to 20, and

x is a positive integer less than 40, y is a positive integer less than 100, z is a positive integer less than 40, and w, x, y, and z together are selected such that the molecular weight of the first urethane acrylate oligomer is less than 20,000.

- 12. (Withdrawn) The liquid stereolithography resin of claim 11, wherein M¹ is a straight, branched, or cyclic alkylene.
- 13. (Withdrawn) The liquid stereolithography resin of claim 11, wherein M¹ is an acylalkylene or acylarylene.
- 14. (Withdrawn) The liquid stereolithography resin of claim 13, wherein M² is a straight, branched, or cyclic alkylene.
- 15. (Withdrawn) The liquid stereolithography resin of claim 11, wherein M² is a straight, branched, or cyclic alkylene.

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- 16. (Withdrawn) The liquid stereolithography resin of claim 11, wherein L is branched or unbranched C_1 - C_4 alkyl.
- 17. (Withdrawn) The liquid stereolithography resin of claim 11, wherein the first acrylate monomer has formula (II):

$$A'-O-R^2-(O-A')_n$$
 (II)

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wherein

 R^2 is a monovalent or polyvalent moiety selected from the group consisting of a C_1 - C_{12} aliphatic group, an aromatic group, and a poly(C_1 - C_4 branched or unbranched alkyl ether), R^2 being optionally substituted with alkyl, cycloalkyl, alkenyl, cycloalkenyl, alkynyl, acyl, alkoxy, hydroxyl, hydroxylalkyl, halo, haloalkyl, amino, aryl, or aralkyl,

n is an integer ranging from 0 to 5, and each A' has the formula:

wherein R^1 is hydrogen or lower alkyl, each L independently is C_1 - C_4 alkyl, and w is an integer ranging from 0 to 20.

18. (Withdrawn) The liquid stereolithography resin of claim 1, wherein the first acrylate monomer has formula (II):

$$A'-O-R^2-(O-A')_n$$
 (II)

wherein

 R^2 is a monovalent or polyvalent moiety selected from the group consisting of a C_1 - C_{12} aliphatic group, an aromatic group, and a poly(C_1 - C_4 branched or unbranched alkyl ether), R^2 being optionally substituted with alkyl, cycloalkyl, alkenyl, cycloalkenyl, alkynyl, acyl, alkoxy, hydroxyl, hydroxylalkyl, halo, haloalkyl, amino, aryl, or aralkyl,

n is an integer ranging from 0 to 5, and each A' has the formula:

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$$-(L-O)_{w}^{O}$$

wherein R^1 is hydrogen or lower alkyl, each L independently is C_1 - C_4 alkyl, and w is an integer ranging from 0 to 20.

- 19. (Withdrawn) The liquid stereolithography resin of claim 18, wherein L is branched or unbranched C_1 - C_4 alkyl.
- 20. (Withdrawn) The liquid stereolithography resin of claim 1, wherein the polymerization modifier includes a second acrylate monomer.
- 21. (Withdrawn) The liquid stereolithography resin of claim 20, wherein the second acrylate monomer has formula (III):

$$(R^3)_k - C - \left[\left(L' - O \right)_i - A'' \right]_i \qquad (III)_i$$

wherein

j is 1, 2, 3 or 4,

k is equal to 4-j,

 R^3 is hydrogen or C_1 - C_4 branched or unbranched alkyl, each L' independently is C_1 - C_4 branched or unbranched alkyl, each i independently is 0, 1, 2 or 3, and

each A" independently has the formula:

$$-(L-O)$$
 R^1

wherein R^1 is hydrogen or lower alkyl, each L independently is C_1 - C_4 branched or unbranched alkyl, and w is an integer ranging from 0 to 20.

22. (Withdrawn) The liquid stereolithography resin of claim 1, wherein the polymerization modifier includes a second urethane acrylate oligomer.

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- 23. (Withdrawn) The liquid stereolithography resin of claim 1, wherein the polymerization modifier is selected from the group consisting of a trimethylolpropane triacrylate, a bisphenol A dimethacrylate, a tripropyleneglycol diacrylate, a pentaerythritol tetraacrylate, a 2-(2-ethoxyethoxy)ethylacrylate, a tris(2-hydroxyethyl)isocyanurate triacrylate, an isobornyl acrylate, and mixtures thereof.
- 24. (Withdrawn) The liquid stereolithography resin of claim 1, wherein the polymerization modifier includes isobornyl acrylate.
- 25. (Withdrawn) The liquid stereolithography resin of claim 1, further comprising a stabilizer.
- 26. (Withdrawn) The liquid stereolithography resin of claim 25, wherein the stabilizer is selected from the group consisting of Tinuvin 292 (bis(1,2,2,6,6-pentamethyl-4piperidyl)sebacate and 1-methyl-10-(1,2,2,6,6-pentamethyl-4-piperidyl)sebacate), Tinuvin 765 (bis(1,2,2,6,6-pentamethyl-4-piperidyl)sebacate), MEQH (4-methoxyphenol), LA-32 2-(2'hydroxy-5'-methylphenyl)benzotriazole, LA-82 1,2,2,6,6-pentamethyl-4-piperidyl methacrylate and Chimassorb 81 (2-hydroxy-4-octyloxybenzophenone).
- 27. (Withdrawn) The liquid stereolithography resin of claim 1, wherein the first urethane acrylate oligomer is Sartomer CN964, the first acrylate monomer is Sartomer SR454 ethoxylated (3) trimethylolpropane acrylate, and the polymerization modifier is selected from the group consisting of Sartomer SR506 isobornyl acrylate, Sartomer SR494 ethoxylated (5) pentaerythritol tetraacrylate, Sartomer CN965, Sartomer SR368 tris-(2hydroxyethyl)isocyanurate triacrylate, and mixtures thereof.
- 28. (Withdrawn) The liquid stereolithography resin of claim 27, wherein the resin includes 5-35 weight % Sartomer CN964 and 0.5-25 weight % Sartomer SR454 ethoxylated (3) trimethylolpropane acrylate.

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- 29. (Withdrawn) The liquid stereolithography resin of claim 28, wherein the resin includes 0.5-20 weight % Sartomer SR506 isobornyl acrylate.
- 30. (Withdrawn) The liquid stereolithography resin of claim 28, wherein the resin includes 15-45 weight % Sartomer SR494 ethoxylated (5) pentaerythritol tetraacrylate.
- 31. (Withdrawn) The liquid stereolithography resin of claim 28, wherein the resin includes 0.5-25 weight % Sartomer CN965.
- 32. (Withdrawn) The liquid stereolithography resin of claim 28, wherein the resin includes 5-35 weight % Sartomer SR368 tris-(2-hydroxyethyl)isocyanurate triacrylate.
- 33. (Withdrawn) The liquid stereolithography resin of claim 1, wherein the first urethane acrylate oligomer is Sartomer CN963, the first acrylate monomer is Sartomer SR306 tripropyleneglycol diacrylate, and the polymerization modifier is selected from the group of Sartomer CN970H75, Sartomer CD540 ethoxylated (4) bisphenol A dimethyacrylate, Sartomer SR506 isobornyl acrylate, and mixtures thereof.
- 34. (Withdrawn) The liquid stereolithography resin of claim 33, wherein the resin includes 40-70 weight % Sartomer CN963, and 5-35 weight % Sartomer SR306 tripropyleneglycol diacrylate.
- 35. (Withdrawn) The liquid stereolithography resin of claim 34, wherein the resin includes 0.5-15 weight % Sartomer CN970H75.
- 36. (Withdrawn) The liquid stereolithography resin of claim 34, wherein the resin includes 0.5-15 weight % Sartomer CD540 ethoxylated (4) bisphenol A dimethyacrylate.
- 37. (Withdrawn) The liquid stereolithography resin of claim 34, wherein the resin includes 5-35 weight % Sartomer SR506 isobornyl acrylate.

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- 38. (Withdrawn) The liquid stereolithography resin of claim 1, wherein the first urethane acrylate oligomer is **Sartomer** CN966, the first acrylate monomer is **Sartomer SR506** isobornyl acrylate, and the polymerization modifier is selected from the group consisting of **Sartomer SR506** isobornyl acrylate, **Sartomer CD540** ethoxylated (4) bisphenol A dimethyacrylate, and mixtures thereof.
- 39. (Withdrawn) The liquid stereolithography resin of claim 38, wherein the resin includes 10-40 weight % Sartomer CN966 and 0.5-25 weight % Sartomer SR506 isobornyl acrylate.
- 40. (Withdrawn) The liquid stereolithography resin of claim 38, wherein the resin includes 6-35 weight % Sartomer SR506 isobornyl acrylate.
- 41. (Withdrawn) The liquid stereolithography resin of claim 38, wherein the resin includes 25-55 weight % Sartomer CD540 ethoxylated (4) bisphenol A dimethyacrylate.
- 42. (Withdrawn) The liquid stereolithography resin of claim 1, wherein the first urethane acrylate oligomer is **Sartomer** CN990, the first acrylate monomer is **Sartomer SR506** isobornyl acrylate, and the polymerization modifier is selected from the group consisting of **Sartomer** CN131, **BYK Chemie BYK UV 3500** a polyether modified acryl functional polydimethylsiloxane, and mixtures thereof.
- 43. (Withdrawn) The liquid stereolithography resin of claim 42, wherein the resin includes 50-80 weight % Sartomer CN990 and 0.5-20 weight % Sartomer SR506 isobornyl acrylate.
- 44. (Withdrawn) The liquid stereolithography resin of claim 43, wherein the resin includes 5-35 weight % Sartomer CN131.

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- 45. (Withdrawn) The liquid stereolithography resin of claim 43, wherein the resin includes 0.5-15 weight % BYK-Chemie-BYK UV 3500 a polyether modified acryl functional polydimethylsiloxane.
- 46. (Withdrawn) The liquid stereolithography resin of claim 1, wherein the first urethane acrylate oligomer is Sartomer CN973, the first acrylate monomer is Sartomer SR506 isobornyl acrylate, and the polymerization modifier is Sartomer SR506 isobornyl acrylate.
- (Withdrawn) The liquid stereolithography resin of claim 46, wherein the resin 47. includes 45-75 weight % Sartomer CN973 and 10-70 weight % Sartomer SR506 isobornyl acrylate.
- 48. (Withdrawn) The liquid stereolithography resin of claim 1, wherein the first urethane acrylate oligomer is Sartomer CN963, the first acrylate monomer is Sartomer SR306 tripropylene glycol diacrylate, and the polymerization modifier is selected from the group consisting of Sartomer CN2400, Sartomer SR506 isobornyl acrylate, and mixtures thereof.
- 49. (Withdrawn) The liquid stereolithography resin of claim 48, wherein the resin includes 20-50 weight % Sartomer CN963 and 0.5-25 weight % Sartomer SR306 tripropylene glycol diacrylate.
- 50. (Withdrawn) The liquid stereolithography resin of claim 49, wherein the resin includes 10-40 weight % Sartomer CN2400.
- 51. (Withdrawn) The liquid stereolithography resin of claim 49, wherein the resin includes 10-40 weight % Sartomer SR506 isobornyl acrylate.
- 52. (Withdrawn) The liquid stereolithography resin of claim 1, wherein the first urethane acrylate oligomer is Sartomer CN966, the first acrylate monomer is Sartomer SR506

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<u>isobornyl acrylate</u>, and the polymerization modifier is selected from the group consisting of Sartomer CN131 and Sartomer SR506 isobornyl acrylate.

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- 53. (Withdrawn) The liquid stereolithography resin of claim 52, wherein the resin includes 35-60 weight % Sartomer CN966 and 10-25 weight % Sartomer SR506 isobornyl acrylate.
- 54. (Withdrawn) The liquid stereolithography resin of claim 52, wherein the resin includes 10-45 weight % Sartomer SR506 isobornyl acrylate.
- 55. (Withdrawn) The liquid stereolithography resin of claim 52, wherein the resin includes 5-35 weight % Sartomer CN131.
- 56. (Withdrawn) A liquid stereolithography resin comprising: a first urethane acrylate oligomer having formula (I):

$$A - O = \left(M^{1} - O \right)_{x} \frac{O}{H} N - M^{2} - N = 0 \\ O = \left(M^{1} - O \right)_{z} A \qquad (1)$$

wherein

each M¹ is, independently, an alkylene, an acylalkylene, an oxyalkylene, an arylene, an acylarylene, or an oxyarylene, M¹ being optionally substituted with alkyl, cycloalkyl, alkenyl, cycloalkenyl, alkynyl, acyl, alkoxy, hydroxyl, hydroxylalkyl, halo, haloalkyl, amino, silicone, aryl, or aralkyl,

each M² is, independently, an alkylene or an arylene, M² being optionally substituted with alkyl, cycloalkyl, alkenyl, cycloalkenyl, alkynyl, acyl, alkoxy, hydroxyl, hydroxylalkyl, halo, haloalkyl, amino, silicone, aryl, or aralkyl,

each A, independently, has the formula:

wherein R1 is hydrogen or lower alkyl, each L is, independently, C1-C4 alkyl, and w is an integer

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ranging from 0 to 20, and

x is a positive integer less than 40, y is a positive integer less than 100, z is a positive integer less than 40, and w, x, y, and z together are selected such that the molecular weight of the first urethane acrylate oligomer is less than 20,000;

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a first acrylate monomer having formula (II):

$$A'-O-R^2-(O-A')_n$$
 (II)

wherein

 R^2 is a monovalent or polyvalent moiety selected from the group consisting of a C_1 - C_{12} aliphatic group, an aromatic group, and a poly(C_1 - C_4 branched or unbranched alkyl ether), R^2 being optionally substituted with alkyl, cycloalkyl, alkenyl, cycloalkenyl, alkynyl, acyl, alkoxy, hydroxyl, hydroxylalkyl, halo, haloalkyl, amino, aryl, or aralkyl,

n is an integer ranging from 0 to 5, and each A' has the formula:

wherein R^1 is hydrogen or lower alkyl, each L independently is C_1 - C_4 alkyl, and w is an integer ranging from 0 to 20; and

a polymerization modifier including a second urethane acrylate oligomer, a second acrylate monomer, or a combination thereof.

57. (Withdrawn) The liquid stereolithography resin of claim 56, further comprising a photoinitiator and a stabilizer.

58-67. (Cancelled)